

Modifying titanium implant surfaces with antibacterial copper: Is this feasible?

C. Jung¹, M. de Wild²

¹KKS Ultraschall AG, Medical Surface Center, Steinen, CH, ²University of Applied Sciences Northwestern Switzerland, School of Life Sciences, Muttenz, CH

INTRODUCTION: Implant associated infection is a burden for patients. It may appear not only directly after surgery but also after a long post-surgery period in some cases. Furnishing implant surfaces with infection inhibiting properties would therefore be a very welcomed approach. Here, we introduce the approach for modifying the surface of titanium implants with antibacterial copper. Based on the results of a number of studies [1-6], it is concluded that copper-modifying anodized implant surfaces is a feasible approach and has the potential for industrial up-scaling.

METHODS: Discs of cpTi grade 4 (Ø 12 or 14 mm, 2 mm thick) were anodized and Cu-modified using the spark-assisted anodizing method run in a combined anodizing/deposition process using proprietary electrolyte and proprietary process parameters (KKS TioCel™) [1,2] (Figure 1).

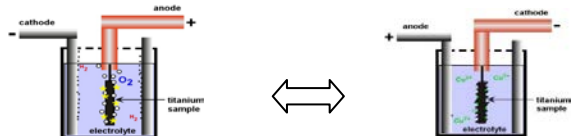


Fig. 1: Sketch of the electrochemical method for combined titanium anodizing (left) and copper depositing/doping process (right).

RESULTS: The anodized discs show a rough fine-porous outermost layer and an underlying conversion layer (Figure 2 left). The R_a -value of the outermost layer is ca. 0.6 μm . Using appropriate electrochemical process parameters, Cu can be deposited onto and/or into the titanium oxide layer as detected by XPS depth profile analysis using Ar^+ sputtering [3] (Figure 2 right).

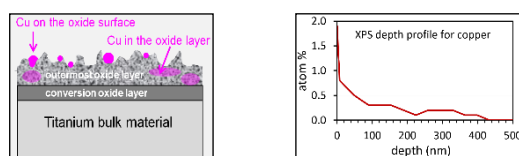


Fig. 2: Sketch of the anodized titanium with Cu onto and into the outermost layer (left) and Cu XPS-depth profile (right).

The copper deposits on the surface have a size of few nanometers up to 2 μm (Figure 3) and are

ablation tests and wear analyses in synthetic bone show a limited loss of copper (< 24%) [4].

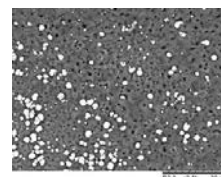


Fig. 3: SEM image of a copper modified titanium surface (Hitachi TM3000, backscattered mode, x2500); white spots are copper deposits.

Studies on the Cu release into simulated body fluid demonstrate that the kinetics follow known release profiles with an initial burst phase followed by a slow phase. After 290 days, all surface copper is released into calcium-free SBF [5]. The viability of human primary gingival fibroblasts (HFIB-G), of immortalized gingival keratinocytes (IHGK) and of an osteosarcoma cell line (SaOs-2) on copper-modified discs was tested [6]. The cells presented slightly different resistance against Cu (fibroblasts < osteoblasts < keratinocytes) with a mean Cu amount of 13 $\mu\text{g}/\text{disc}$ (43 ng/mm^2 ; 4.3 $\mu\text{g}/(\text{ml}$ reaction volume)) for i.e. 50% cell viability (IC_{50}). This value is in the range of the lethal Cu concentration for *Staph. aureus* (~5 $\mu\text{g}/\text{ml}$ [2]) indicating a good antibacterial effect with an acceptable cell viability of 50%.

DISCUSSION & CONCLUSIONS: The physicochemical and biological data obtained so far do strongly indicate that modifying the surface with copper is a feasible approach to give titanium implants an antibacterial property. The electrochemical technique is related to practice applications and has the potential to scale-up.

REFERENCES: ¹C. Jung (2010) *eCM*, **19** (Suppl 2):4. ²C. Jung, N. Ryter, J. Köser, W. Hoffmann, L. Straumann, N. Balimann, F. Meier, M. de Wild, F. Schlottig, I. Martin, U. Pieves (2012) *eCM*, **23** (Suppl 1):16. ³C. Jung, L. Straumann, A. Kessler, U. Pieves, M. de Wild (2014) *BioNanoMat* **15** (S1). ⁴L. Straumann, A. Kessler, U. Pieves, M. de Wild, C. Jung (2014) *eCM*, **28** (Suppl 6):21. ⁵A. Kessler, L. Straumann, U. Pieves, M. de Wild, C. Jung (2014) *eCM*, **27** (Suppl 2):24. ⁶C. Jung, S. Mathes, E. Bono, C. Walker, A. Kessler, L. Straumann, M. de Wild, E.B. de Haller (2015) *eCM*, **29** (Suppl 2):24.